

Publisher's Note: Enhanced Tunneling Electroresistance in Ferroelectric Tunnel Junctions due to the Reversible Metallization of the Barrier
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This Letter was published online on 11 May 2016 with typographical errors in the text on page 4. On page 4, left-hand column, the first sentence of the first paragraph should read as “Our calculations confirm that the tunnel junction indeed exhibits much lower tunneling resistance with polarization pointing into n -SrTiO₃.” The sixteenth line of the same paragraph should read as “on resistance ratio is about 2.3×10^3 .” The Letter has been corrected as of 13 May 2016. The text is correct in the printed version of the journal.